# Dielectric function measurement of emerging semiconductors

### Andrea Crovetto

Postdoc

DTU Nanotech,

Technical University of Denmark

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 $f(x+\Delta x) = \sum_{i=0}^{\infty} \frac{(\Delta x)^{i}}{i!} f^{(i)}(x) = a^{i} + a^{i} +$ 

**DTU Nanotech** Department of Micro- and Nanotechnology

# **Dielectric function of semiconductors**



### Which semiconductors?

• Thin-film sulfide semiconductors for solar cells

#### Why ellipsometry?

- Band gap and absorption coefficient are crucial for solar energy materials
- By comparing the experimental and calculated dielectric function, much can be learned about the electronic properties of those materials

#### Ellipsometry measurement issues?

- Those sulfides for solar cells must be:
  - deposited on a metal back contact
  - annealed in a sulfur atmosphere
  - → Problem 1: Multi-layered substrate
  - → Problem 2: Changes in properties of all layers upon annealing







Step 2: dielectric function of MoS<sub>2</sub> on Mo

 Anneal Mo in a sulfur + N<sub>2</sub> atmosphere to form MoS<sub>2</sub>

MoS<sub>2</sub>

glass substrate

Mo

• <u>2<sup>nd</sup> ellipsometry measurement</u>



A. Crovetto et al., Solar Energy Materials and Solar Cells, 154, 121–129 (2016)

200 nm



**Step 3:** measure the dielectric function of  $Cu_2SnS_3$  on  $MoS_2/Mo$ 

- Deposit a thin layer of Cu<sub>2</sub>SnS<sub>3</sub> on Mo (to keep roughness low)
- Anneal Cu<sub>2</sub>SnS<sub>3</sub> in a **sulfur+N<sub>2</sub>** atmosphere
- <u>3<sup>rd</sup> ellipsometry measurement</u>







Case study: Cu<sub>2</sub>SnS<sub>3</sub> (CTS)





## Two interesting findings:







# Other ellipsometry activities

## non-ideal films



A. Crovetto et al., Thin Solid Films, 582, 203-207 (2015)

# Other ellipsometry activities resistivity mapping



A. Crovetto et al., Journal of Physics D: Applied Physics, 49, 295101 (2016)

# Other ellipsometry activities



## optical measurement of carrier density & mobility

Material: **ZnO:AI** thin films

→ transparent conductor (degenerately doped high-band gap semiconductor)



A. Crovetto et al., Journal of Physics D: Applied Physics, 49, 295101 (2016)

# **Other ellipsometry activities**



## optical measurement of carrier density & mobility



Alternative method:

#### **Burstein-Moss effect**

The band gap increases proportionally to (carrier density)<sup>2/3</sup>



A. Crovetto et al., Journal of Physics D: Applied Physics, 49, 295101 (2016)

# **Summary of activities**



**Dielectric function** determination of new thin-film semiconductors

Learning about their electronic properties

□ Phase analysis of "non-ideal" thin films

□ Thickness **mapping** (for its own sake and for resistivity mapping)

□ All-optical determination of **electrical properties** of transparent conductive materials